Dongester. On 12/8/05

PATENT Atty. Dkl. No. APPW/008241/PPC/ECP/CKIM

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Sun et al.

Serial No.: 10/616,097

Confirmation No.: 1645

Filed:

July 8, 2003

For:

Multiple-Step

Electrodeposition Process

for Direct Copper Plating

on Barrier Metals

Group Art Unit: 1753

Examiner:

Edna Wong

MAIL STOP AF Commissioner for Patents P.O. Box 1450

Alexandria, VA 22313-1450

Dear Sir.

CERTIFICATE OF FACSIMILE TRANSMISSION UNDER 37 CFR 1.8

I hereby certify that this correspondence and the documents referred to as attached therein are being facsimile transmitted to the U.S. Patent and Trademark Office to the fax number indicated by the Examiner, namely, fax number 571.273.8300 to the attention of the named Examiner, on the date below.

December 2, 2005 Date

RESPONSE TO FINAL OFFICE ACTION DATED OCTOBER 4, 2005

In response to the Final Office Action dated October 4, 2005, having a shortened statutory period for response set to expire on January 4, 2006, please enter this response and reconsider the claims pending in the application for reasons discussed below. Although the Applicant believes that no additional fees are due in connection with this response, the Commissioner is hereby authorized to charge counsel's Deposit Account No. 20-0782/APPM/008241/KMT, for any fees, including extension of time fees or excess claim fees, required to make this response timely and acceptable to the Office.

Amendments to the Claims begin on page 2 of this paper. Remarks begin on page 8 of this paper.